

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: :
Akiko HEMMI et al. : Group Art Unit: 1751
Serial No.: 09/887,345 : Examiner: B. Mruk
Filed: June 25, 2001 :
For: LOW-MOLECULAR (METH)ACRYLIC :
ACID (SALT)-BASED POLYMER AND ITS :
PRODUCTION PROCESS AND USES :

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In accordance with 37 C.F.R. § 1.97 and § 1.98, Applicants bring the disclosure attached and listed on completed Form PTO-1449 to the Examiner's attention and request that it be considered and made of record in this application.

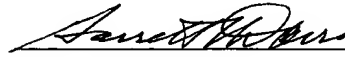
The enclosed document was cited in Applicants' corresponding Japanese application, and a copy of the Communication from the Japanese Patent Office dated February 10, 2004 is enclosed.

Applicants are enclosing Japanese Patent Publication JP-A-143737/2000 only since the remaining documents disclosed in the Japanese Communication have been previously submitted to the Patent Office at the time of filing.

Since the enclosed patents were cited in the Japanese Communication not more than three months prior to the submission of this Information Disclosure Statement, it is believed that no fee is required for consideration of these patents. However, the Examiner is hereby

authorized to charge any fees which may become due in connection with this communication
or credit any overpayment to Deposit Account No. 18-2220.

Respectfully submitted,



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Dated: March 5, 2004

Date
Considered